

Characterizing ultra-low emittance electron beams using structured light fields

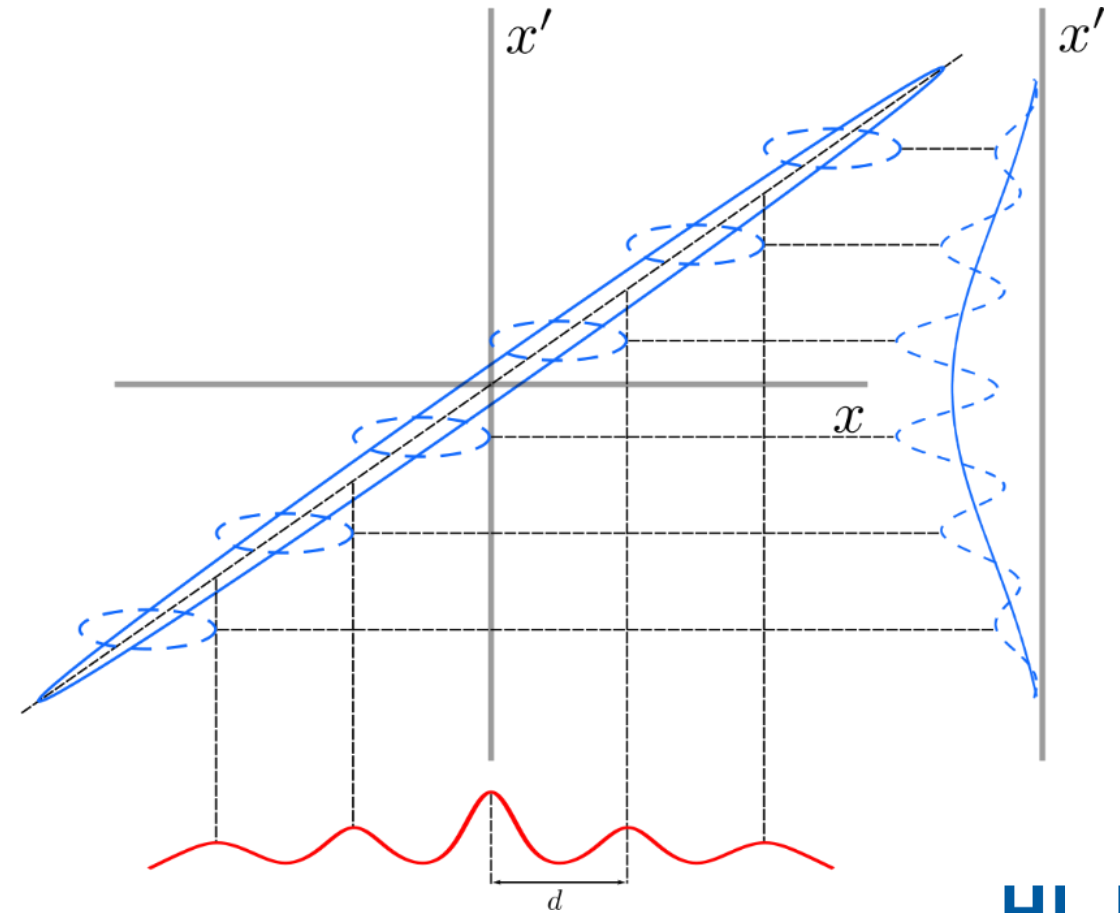
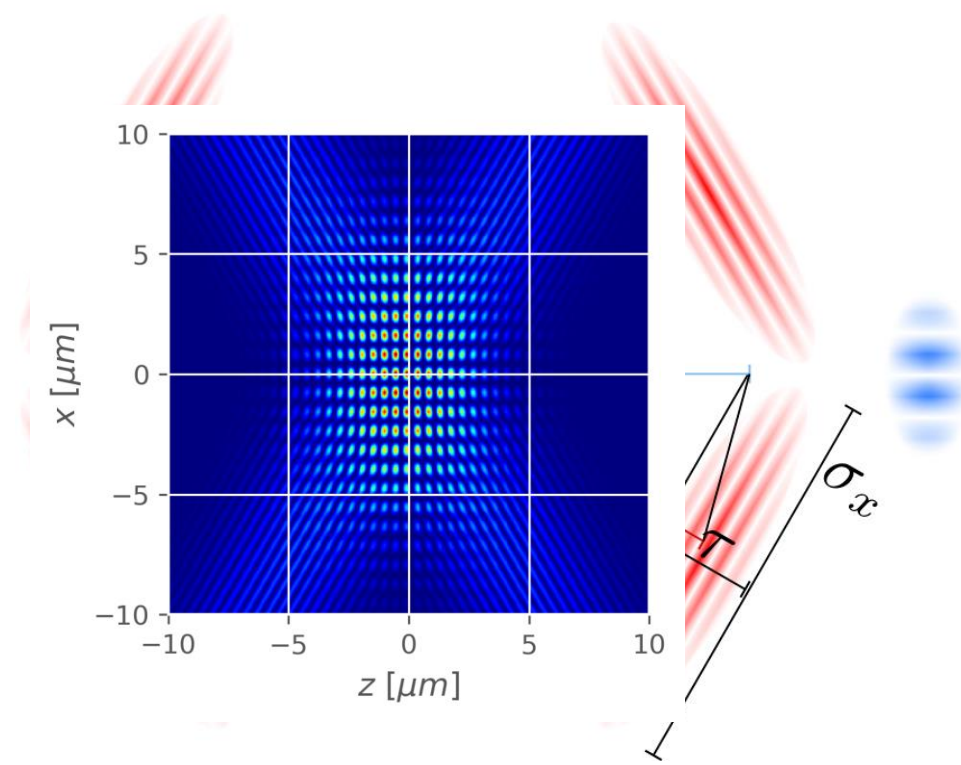
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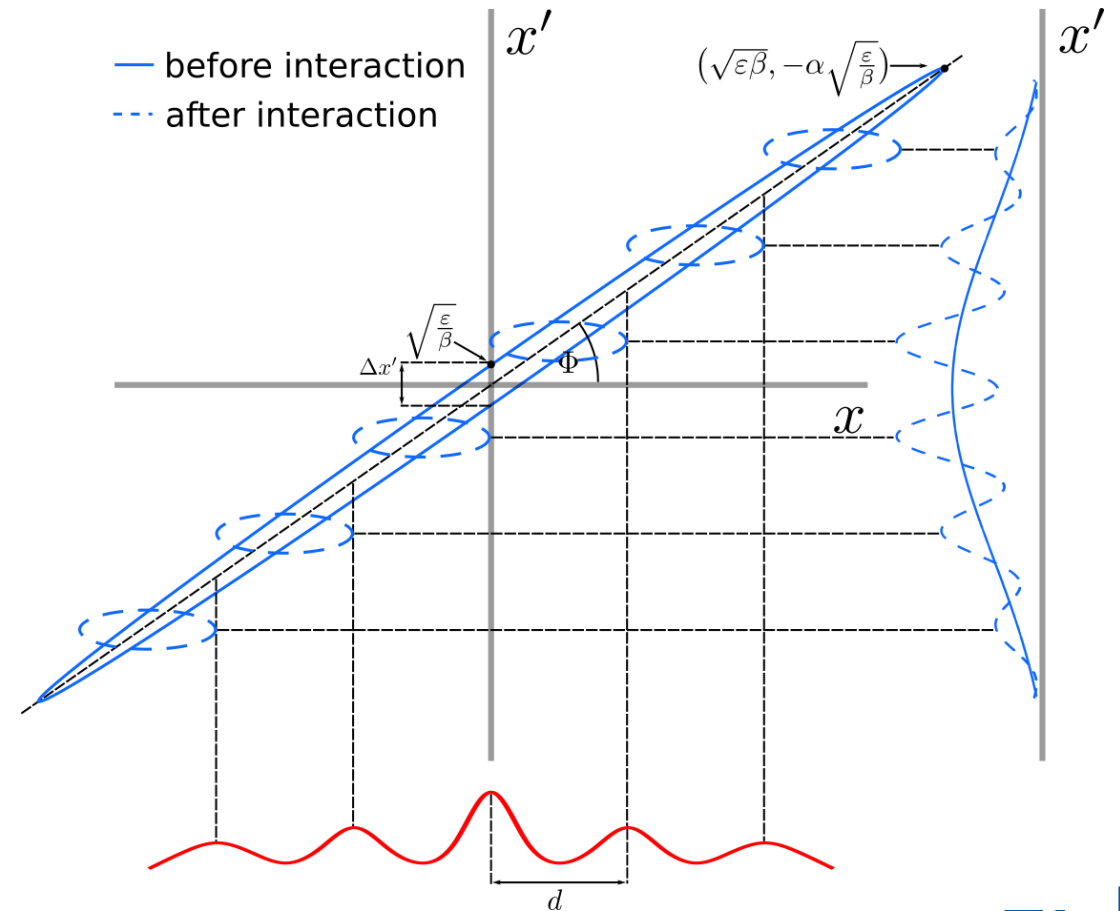
³ Deutsches Elektron-Synchrotron DESY

Schematic measurement setup



Method theory

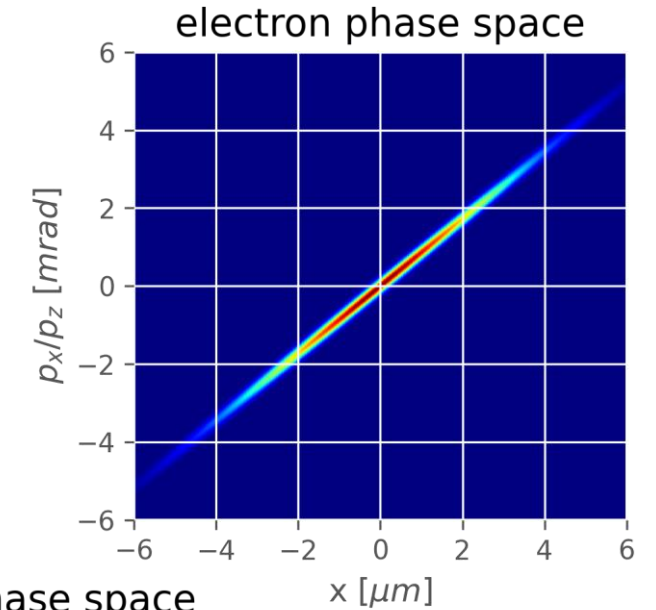
- $\varepsilon = \gamma x^2 + 2\alpha x x' + \beta x'^2$ [1]
- $\Delta x' = 2 \sqrt{\frac{\varepsilon}{\beta(z)}}$
- $d > \frac{\Delta x'}{\tan \Phi} \approx 2\sigma_x(0)$



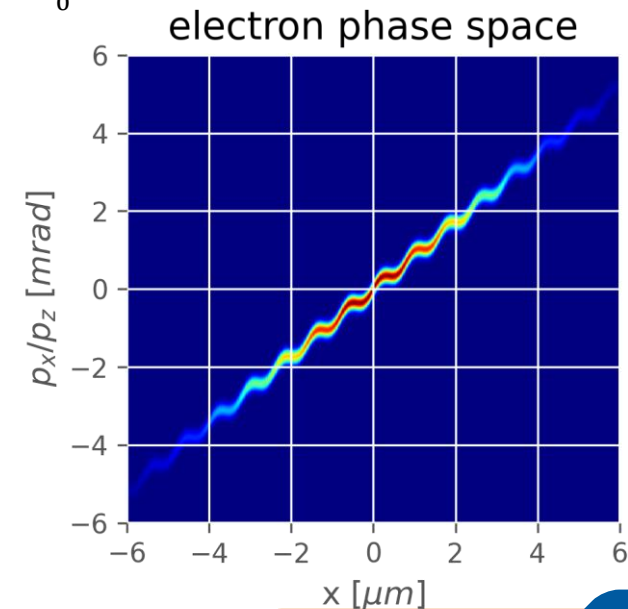
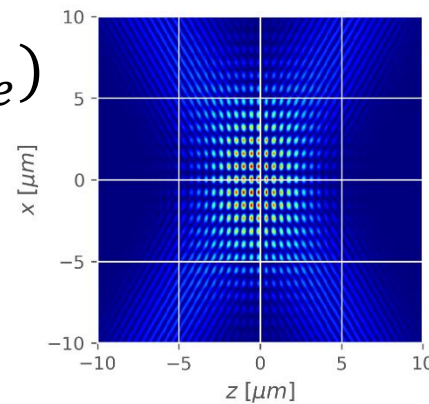
[1] K.Flottmann *et al.*, *Phys. Rev. STAB* **6** (2003)

Analytic Solution

- $n_e(x, p_x) = ne_0 \cdot \exp\left(-\frac{p_x^2}{2\sigma_{px_0}^2} - \frac{x^2}{2\sigma_{x_0}^2}\right)$
- $n_e(x, p_x) = ne_0 \cdot \exp\left(-\frac{p_x^2}{2\sigma_{px_0}^2} - \frac{((p_x - \Delta p_x)/(p_z \tan \Phi) - x)^2}{2\sigma_{x_0}^2}\right)$

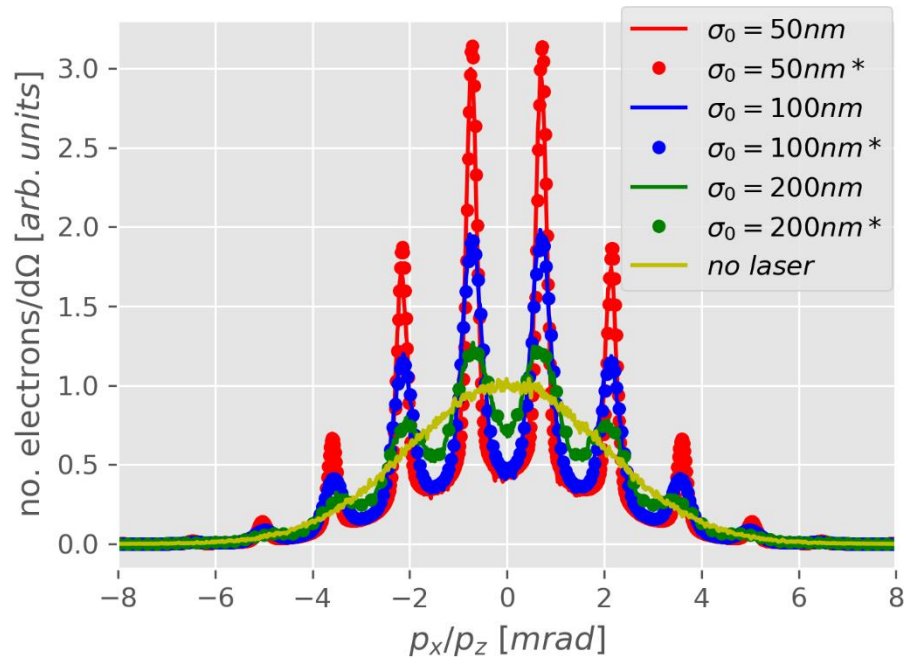


- $\Delta p_x = \langle F_{pond} \rangle \cdot t_{int}(\gamma_e)$

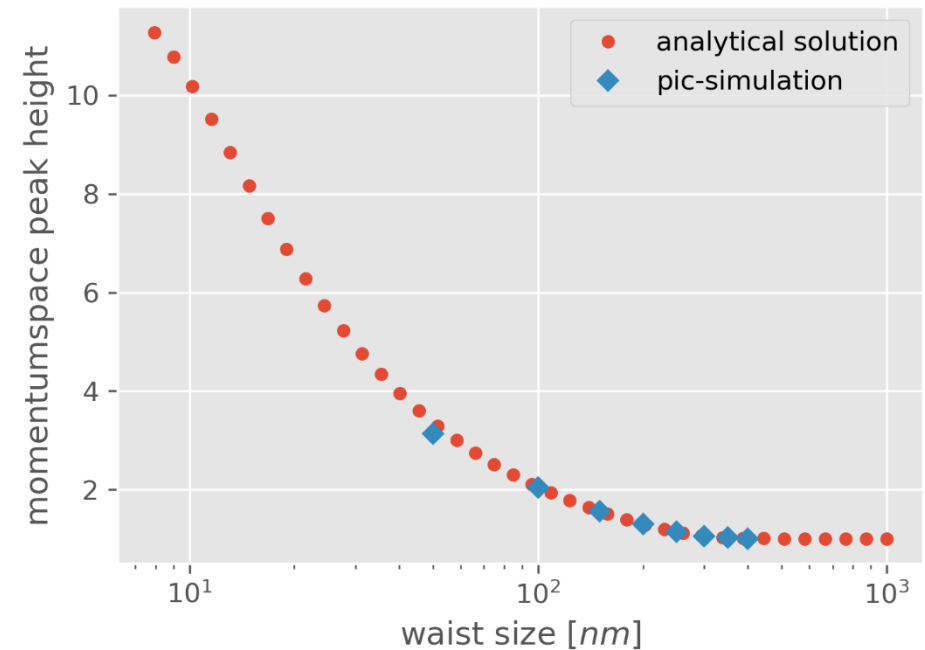


PIC-Simulation vs Analytical solution

PIC and Analytical-Solution

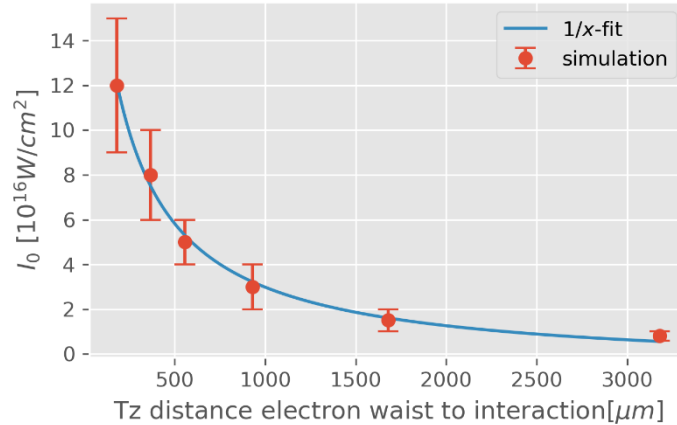


Analytical extrapolation

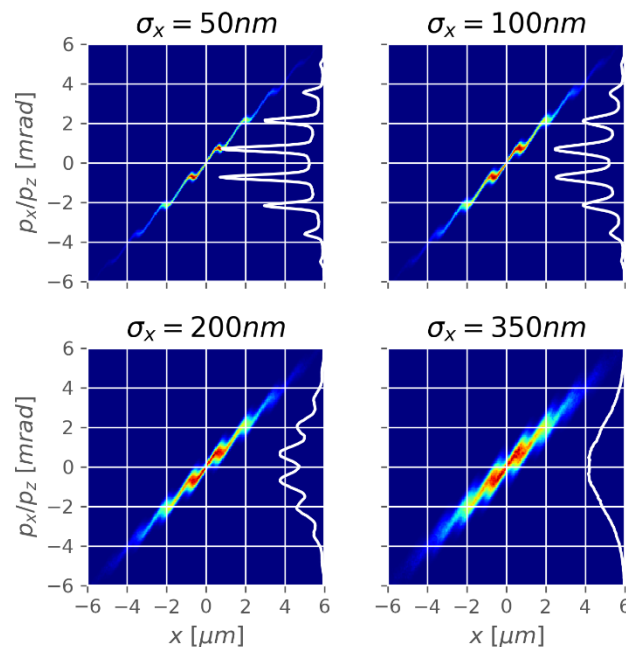


$$\varepsilon_n = \beta\gamma\sigma_{x0}\sigma_{px0} = 100 \cdot 100\text{nm} \cdot 2\text{mrad} = 0.020 \text{ mm mrad}$$

Measurement Procedure



- Choosing a desired distance between electron beam waist and interaction position with laser intensity accordingly



- From the measured modulation depth in the momentum space source size can be deduced by comparing with pic/analytic solution

Summary/Outlook

- ✓ Electron density modulation with moderate laser intensity (10^{17} W/cm²) achievable
- ✓ Normalized emittances down to 0.01 mm mrad have been simulated
- ✓ Method is suited for mono energetic beams (from RF linacs) and LWFA beams with broader bandwidth
- Test of the concept in an experiment at JETI 200 in 2021

Thank you for your attention!